

N THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Kwang Su Choe, et al.

Docket: YOR920030293US1 (16818)

Serial No:

To be assigned 10/674,647

Date:

Filed:

Herewith

9/30/2003

For: THIN BURIED OXIDES BY LOW-DOSE

OXYGEN IMPLANTATION INTO MODIFIED SILICON

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

ASSOCIATE POWER OF ATTORNEY AND REQUEST FOR CHANGE OF MAILING ADDRESS

Sir:

Applicant(s), by (his/her/their) attorneys of record, hereby grant(s) an Associate Power of Attorney to:

FRANK S. DIGIGLIO, Reg. 31,346; LEOPOLD PRESSER, Reg. No. 19,827; STEVEN FISCHMAN, Reg. No. 34,594; JOHN S. SENSNY, Reg. No. 28,757; EDWARD W. GROLZ, Reg. No. 33,705; and WILLIAM C. ROCH, Reg. No. 24,972.

with full power of substitution to prosecute this application and transact all business in the United States Patent and Trademark Office in connection therewith.

Applicant(s) further request(s) that all future correspondence in connection with this application be directed and addressed to:

> STEVEN FISCHMAN, ESO. SCULLY, SCOTT, MURPHY AND PRESSER 400 Garden City Plaza Garden City, New York 11530 Direct all telephone calls to: (516) 742-4343.

> > Respectfully submitted:

Registration No. 25,933

SCULLY, SCOTT, MURPHY & PRESSER 400 Garden City Plaza Garden City, New York 11530 (516) 742-4343

BEST AVAILABLE COPY